

L Number	Hits	Search Text	DB	Time stamp
1	17189	216/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 09:02
2	60004	101/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 09:02
3	50922	347/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 09:02
4	34924	205/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 09:03
5	116634	430/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 09:03
6	270901	216/\$.ccls. 101/\$.ccls. 347/\$.ccls. 205/\$.ccls. 430/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 09:03
7	5036	(216/\$.ccls. 101/\$.ccls. 347/\$.ccls. 205/\$.ccls. 430/\$.ccls.) and (thermal adj transfer)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 09:20
8	10530	(thermal adj transfer) same printing	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 09:21
9	2499	((thermal adj transfer) same printing) and (216/\$.ccls. 101/\$.ccls. 347/\$.ccls. 205/\$.ccls. 430/\$.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 09:21
10	1558	((thermal adj transfer) same printing) same (laser or irradiat\$4 or uv or ultraviolet or radiat\$4 or expos\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 09:22
11	554	(((thermal adj transfer) same printing) same (laser or irradiat\$4 or uv or ultraviolet or radiat\$4 or expos\$4)) and (216/\$.ccls. 101/\$.ccls. 347/\$.ccls. 205/\$.ccls. 430/\$.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 09:38
12	411	(((thermal adj transfer) same printing) same (laser or irradiat\$4 or uv or ultraviolet or radiat\$4 or expos\$4)) same (etch\$4 or plat\$4 or pattern\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 11:21

13	191	(((thermal adj transfer) same printing) same (laser or irradiat\$4 or uv or ultraviolet or radiat\$4 or expos\$4)) same (etch\$4 or plat\$4 or pattern\$4)) and (216/\$.ccls. 101/\$.ccls. 347/\$.ccls. 205/\$.ccls. 430/\$.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 09:38
14	18	(((thermal adj transfer) same printing) same (laser or irradiat\$4 or uv or ultraviolet or radiat\$4 or expos\$4)) same (etch\$4 or plat\$4 or pattern\$4)) same ablat\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/02 11:21